

Optical Scanning Apparatus, Image Forming Apparatus,
and Methods of ^{Performing} ~~Manufacturing~~ ^{Using Optical Scanning} Apparatus
and Image Forming Apparatus

5 BACKGROUND OF THE INVENTION

Field of the Invention

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The present invention relates to an optical scanning apparatus and image forming apparatus and, more particularly, to an optical scanning apparatus which uses an OFS (Over Field Scanner) optical system designed to receive a light beam emitted from a light source means within a range wider than the width of a deflecting surface in the main scanning direction and optically scan a photosensitive member and is suitably used for an image forming apparatus such as a digital copying machine or laser beam printer, and methods of manufacturing the optical scanning apparatus and image forming apparatus.

Related Background Art

20 Recently, as digital copying machines, LBPs (Laser Beam Printers), and the like become faster in operation, an OFS optical system which can perform scanning with an increased number of deflecting surfaces (reflecting surfaces) of a polygon mirror serving as an optical deflector, a multi-beam scanning optical apparatus based on a scheme of simultaneously forming a plurality of scanning lines with an increased

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number of light sources (emission points), and the like have been proposed. In addition, a faster apparatus can be implemented by combining the above two types of techniques.

5 In an OFS optical system, part of an incident light beam having a Gaussian intensity distribution is cut by a deflecting surface of a polygon mirror to form a scanning light beam (reflected light beam). For this reason, the scanning light beam has an intensity
10 distribution, which in turn forms a scanning line illuminance distribution on a scanned surface, resulting in the density irregularity of an image.

Conventionally, therefore, as disclosed in Japanese Laid-Open Patent Application No. 11-14923, an
15 ND filter with gradation serving as a light amount adjusting means for adjusting the exposure on a scanned surface is disposed between a light source and an optical deflector and is designed to be movable in the gradation direction and rotatable in a plane including
20 the filter surface, thereby reducing the intensity distribution of a scanning beam after deflection.

Japanese Laid-Open Patent Application No. 9-96769 discloses a technique of correcting the asymmetry of a light amount distribution by shifting or tilting a
25 light source in the main scanning direction with respect to a collimator lens.

In this method, the light source is shifted from

the optical axis of the collimator lens to cause a parallel light beam emerging from the collimator lens to emerge obliquely with respect to the optical axis of the collimator lens. With this operation, the light beam incident on a polygon surface is shifted in the main scanning direction, thereby making adjustment such that the center of the intensity distribution of the light beam coincides with the center of the polygon surface.

10 In this method, however, since the light source is moved relative to the collimator lens, a field angle is set, and a focus error occurs at the same time. The influences of these phenomena are enhanced as the focal length of the collimator lens is decreased to increase the use efficiency of light from the light source.

15 In general, the focus adjustment sensitivity in the main scanning direction is proportional to the square of the lateral magnification of the overall system, and the focus adjustment precision of the light source and collimator lens is about 5 μm . To prevent a focus error in the light source, a high mechanical precision is required, resulting in an increase in cost.

20 In addition, since the collimator lens and light sources are discrete components, if the light source fails, the optical scanning apparatus must be replaced, requiring a high cost in terms of market

serviceability. If the light source and collimator lens are integrated into one unit, a deterioration in this light source can be coped with by replacing the unit with another.

5 Although optimal filters for the design center values of an optical system can be prepared, the influences of assembly tolerance, variations in parts, and the like are too large to be neglected. If an assembled semiconductor laser chip is tilted in the
10 main scanning direction with respect to the optical axis, in particular, the intensity center of a substantially parallel light beam emerging from the collimator lens shifts from the optical axis center. As a consequence, the intensity distribution of an
15 incident light beam cut by the polygon mirror becomes asymmetrical. In an extreme case, the intensity peak of a scanning line formed on a scanned surface is located outside the effective scanning range, and reaches a value twice or more the initial value upon
20 tilting of the intensity distribution. In such a case, no stable effect can be expected even with measures such as a filter.

SUMMARY OF THE INVENTION

25 It is an object of the present invention to provide an optical scanning apparatus, in which the laser unit is configured to be shifted by the shift

adjusting means in a predetermined direction with
respect to the optical axis of the incident optical
system or/and the tilt angle of the semiconductor laser
chip is set to fall within an allowable range so as to
5 make an illuminance distribution, obtained when a
scanned surface is scanned with scanning lines, almost
symmetrical about the scanning center axis so that the
asymmetry of an illuminance distribution, obtained when
the scanned surface is scanned with scanning lines, due
10 to variations in components, assembly errors, and the
like can be reduced.

According to an aspect of the present invention,
there is provided an optical scanning apparatus
comprising a laser unit formed by integrating a light
15 source and collimator lens, an incident optical system
for making a light beam emerging from the laser unit
strike an optical deflector while keeping the light
beam wider than a width of a deflecting surface of the
optical deflector in a main scanning direction, and an
20 imaging optical system for forming the light beam
reflected/deflected by the optical deflector into an
image on a scanned surface, wherein the laser unit is
shifted by shift adjusting means in a predetermined
direction with respect to the optical axis of the
25 incident optical system so as to make an illuminance
distribution of scanning lines on the scanned surface
become substantially symmetrical about a scanning

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central axis.

According to another aspect of the present invention, "substantially symmetrical" indicates that an illuminance distribution on the scanned surface falls within $\pm 5\%$ with respect to the axis in an effective scanning range.

According to still another aspect of the present invention, the predetermined direction is the main scanning direction or/and a sub-scanning direction.

According to still another aspect of the present invention, the light beam emerging from the laser unit is a substantially parallel light beam.

According to still another aspect of the present invention, when the optical axes of the incident optical system and imaging optical system are projected on a main scanning cross-section, the optical axes substantially coincide with each other.

According to still another aspect of the present invention, the light beam emerging from the incident optical system is obliquely incident on the deflecting surface of the optical deflector in a sub-scanning cross-section.

According to still another aspect of the present invention, the light beam emerging from the incident optical system is obliquely incident on the deflecting surface of the optical deflector in a main scanning cross-section.

According to still another aspect of the present invention, the incident optical system is arranged in a main scanning cross-section based on the optical deflector.

5 According to still another aspect of the present invention, the incident optical system comprises a stop plate, and the laser unit is shifted by the shift adjusting means in a predetermined direction with respect to the optical axis of the incident optical system such that a ratio of intensities of two light
10 beams obtained by splitting a light beam passing through the stop plate in two in the main scanning direction at a stop center becomes not more than 10%.

 According to still another aspect of the present
15 invention, a tilt angle of the light source in the main scanning direction is set to not more than $\pm 2.5^\circ$ with respect to the optical axis of the collimator lens.

 According to still another aspect of the present invention, the laser unit is shifted in advance in the
20 main scanning direction with respect to the optical axis of the incident optical system by an amount corresponding to an incident angle at which the light beam emerging from the incident optical system is obliquely incident on the deflecting surface of the
25 optical deflector in a main scanning cross-section.

 According to still another aspect of the present invention, there is provided an image forming apparatus

comprising the optical scanning apparatus described above, a photosensitive member placed on the scanned surface, a developing unit for developing an electrostatic latent image formed on the photosensitive member by a light beam scanned by the optical scanning apparatus into a toner image, a transfer unit for transferring the developed toner image onto a transfer medium, and a fixing unit for fixing the transferred toner image on the transfer medium.

10 According to still another aspect of the present invention, there is provided an image forming apparatus comprising the optical scanning apparatus described above, and a controller for converting code data input from an external device into an image signal, and
15 inputting the signal to the optical scanning apparatus.

 According to still another aspect of the present invention, there is provided a method of manufacturing an optical scanning apparatus including a laser unit formed by integrating a light source and collimator
20 lens, an incident optical system for making a light beam emerging from the laser unit strike an optical deflector while keeping the light beam wider than a width of a deflecting surface of the optical deflector in a main scanning direction, and an imaging optical
25 system for forming the light beam reflected/deflected by the optical deflector into an image on a scanned surface, comprising the step of causing shift adjusting

means to shift the laser unit in a predetermined direction with respect to the optical axis of the incident optical system so as to make an illuminance distribution of scanning lines on the scanned surface become substantially symmetrical about a scanning central axis.

According to still another aspect of the present invention, the predetermined direction is the main scanning direction or/and a sub-scanning direction.

According to still another aspect of the present invention, there is provided a method of manufacturing an image forming apparatus by forming the optical scanning apparatus manufactured by the method described above, and a controller for converting code data input from an external device into an image signal and inputting the signal to the optical scanning apparatus.

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a main scanning sectional view of the first embodiment of the present invention;

Fig. 2 is a sub-scanning sectional view of the first embodiment of the present invention;

Figs. 3A, 3B, and 3C are views showing the relationship between the tilt of a semiconductor laser chip and the shift of a laser unit;

Fig. 4 is a main scanning sectional view of the second embodiment of the present invention;

Fig. 5 is a sub-scanning sectional view of the second embodiment of the present invention; and

Fig. 6 is a view showing an image forming apparatus according to the present invention.

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DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Fig. 1 is a sectional view (main scanning cross-section) of the main part of the first embodiment of the present invention in the main scanning direction. Fig. 2 is a sectional view (sub-scanning cross-section) of the main part in the sub-scanning direction.

Note that in this specification, a plane which is perpendicular to the rotational axis of an optical deflector and includes a point on a deflecting surface at which a principal light beam is incident is defined as a main scanning cross-section, and a plane perpendicular to the main scanning cross-section is defined as a sub-scanning cross-section.

Referring to Figs. 1 and 2, a laser unit 1 has a light source 2 formed by a semiconductor laser and a collimator lens 3. The laser unit 1 emits a substantially parallel light beam upon predetermined optical adjustment. The laser unit 1 in this embodiment is configured to be shifted by a shift adjusting means 23 in the main scanning direction with respect to the optical axis of an incident optical

system 21 so as to be subjected to initial adjustment such that the illuminance distribution of scanning lines on a scanned surface 12 becomes almost symmetrical about the scanning central axis.

5 A divergent lens (negative lens) 4 has a negative refracting power and converts the substantially parallel light beam from the collimator lens 3 into a slightly divergent light beam. A stop plate (aperture stop) 5 restricts a passing light beam to shape the
10 beam. A cylindrical lens 6 has a predetermined refracting power only in the sub-scanning direction, and forms a light beam passing through the stop plate 5 into an almost linear image on a deflecting surface (reflecting surface) 10a of an optical deflector 10 (to
15 be described later) in a sub-scanning cross-section. A return mirror 7 reflects the light beam emerging from the laser unit 1 toward the optical deflector 10.

 Note that each of the divergent lens 4, stop plate 5, cylindrical lens 6, return mirror 7, scanning lenses
20 8 and 9 (to be described later), and the like forms one element of the incident optical system 21.

 The optical deflector 10 is a polygon mirror (rotary polyhedral mirror), which is rotated at a constant speed in the direction indicated by an arrow A
25 in Fig. 1 by a driving means (not shown) such as a motor.

 An imaging optical system 22 has f- θ

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characteristics and imaging ability. The imaging optical system 22 includes a scanning lens system (f- θ lens system) 24 having the first and second scanning lenses 8 and 9 with predetermined powers in the main scanning direction and a long cylindrical lens (long lens) 11 having a predetermined power in only the sub-scanning direction. The imaging optical system 22 forms a light beam deflected by the optical deflector 10 into an image on the scanned surface 12, and makes the deflecting surface 10a of the optical deflector 10 and scanned surface 12 substantially optically conjugate to each other in a sub-scanning cross-section to correct a tilt of the deflecting surface. The long lens 11 changes the refracting power in a sub-scanning cross-section in the longitudinal direction of the lens to keep a spot diameter and curvature of field on the scanned surface 12 in the sub-scanning direction constant. The long lens 11 is formed by molding plastic to acquire a required shape. Since the long lens 11 needs no refracting power in the main scanning direction, the two surfaces have the same radius of curvature to let the lens have a shape with a uniform thickness.

The scanned surface 12 is a photosensitive drum surface.

This embodiment is configured such that when the optical axes of the incident optical system 21 and

imaging optical system 22 are projected on a main scanning cross-section, the optical axes almost coincide with each other. That is, the respective elements of the optical systems are configured to make
5 a light beam emerging from the incident optical system 21 strike the deflecting surface 10a from the center or substantially the center of the deflection angle for the optical deflector 10 in a main scanning cross-section.

10 In this embodiment, the optically modulated light beam emitted from the semiconductor laser 2 is converted into a substantially parallel light beam by the collimator lens 3. This light beam is converted into a slightly divergent light beam by the divergent
15 lens 4 and strikes the cylindrical lens 6 after being restricted by the stop plate 5. In a sub-scanning cross-section, the slightly divergent light beam incident on the cylindrical lens 6 converges, passes through the second and first scanning lenses 9 and 8
20 through the return mirror 7, strikes the deflecting surface 10a of the optical deflector 10, and is formed into an almost linear image (a linear image elongated in the main scanning direction) near the deflecting surface 10a. In this case, the light beam to be
25 incident on the deflecting surface 10a is inclined with respect to a plane (a rotating plane of the optical deflector) perpendicular to the rotational axis of the

optical deflector 10 by a predetermined angle within a sub-scanning cross-section including the rotational axis of the optical deflector 10 and the optical axis of the imaging optical system 22 (oblique incident optical system). In a main scanning cross-section, the light beam is transmitted through the second and first scanning lenses 9 and 8 through the return mirror 7 without any change to be converted into a substantially parallel light beam, and strikes the deflecting surface 10a from the center or substantially the center of the deflection angle for the optical deflector 10 (frontal incidence). The width of the substantially parallel light beam in this case is set to be sufficiently larger than the facet width of the deflecting surface 10a of the optical deflector 10 in the main scanning direction (over-field optical system).

The light beam reflected/deflected by the deflecting surface 10a of the optical deflector 10 is guided onto the photosensitive drum surface 12 through the first and second scanning lenses 8 and 9 and long lens 11. By rotating the optical deflector 10 in the direction indicated by the arrow A, the light beam is scanned on the photosensitive drum surface 12 in the direction indicated by an arrow B (main scanning direction).

In this embodiment, as shown in Fig. 2, the optical components ranging from the laser unit 1 to the

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cylindrical lens 6 are arranged on the same optical axis, and the optical axis is set at a predetermined angle with respect to a plane 13 nearly perpendicular to the deflecting surface 10a of the optical deflector 10. A mirror surface 7a of the return mirror 7 is placed in a direction perpendicular to the plane 13 to allow a light beam reflected by the return mirror 7, incident on the optical deflector with a predetermined angle being maintained, and reflected/deflected to separate from the return mirror 7 after being transmitted through the first and second scanning lenses 8 and 9.

Figs. 3A, 3B, and 3C are sectional views (main scanning sectional views), each showing the main part of this embodiment, ranging from the laser unit 1 to the optical deflector 10, and indicating the relationship between the tilt of the semiconductor laser chip and the shift of the laser unit.

Fig. 3A shows an ideal state wherein the chip of the semiconductor laser 2 has no tilt. Referring to Fig. 3A, the center of a light beam emitting from the laser unit 1 coincides with the optical axis L of the incident optical system. That is, the peak (center) of the intensity distribution of the light beam almost coincides with the center of the stop plate 5. In this state, an intensity distribution 14a of the light beam immediately after it is emerging from the laser unit 1

and an intensity distribution 15a of the light beam immediately before it is incident on the optical deflector 10 are symmetrical about the optical axis L of the incident optical system 21. Therefore, an
5 illuminance distribution obtained when scanning lines are scanned on the scanned surface is symmetrical about the axis, and the illuminance distribution difference is small.

Fig. 3B shows a state wherein the chip of the
10 semiconductor laser 2 is mounted at a tilt angle θ with respect to the optical axis L due to variations in components, assembly error, and the like. Referring to Fig. 3B, since the peak of an intensity distribution 14b of a light beam emitted from the semiconductor
15 laser 2 does not pass through the center of the stop plate 5, the light beam is incident on the optical deflector 10 with an intensity distribution 15b asymmetrical about the optical axis L, as show in Fig. 3B. As a consequence, an asymmetrical illuminance
20 distribution is formed on the scanned surface, and a larger illuminance distribution difference is produced.

Fig. 3C shows measures against the above situation in this embodiment. Referring to Fig. 3C, a shift adjusting means (not shown) translates the laser unit 1
25 in the state shown in Fig. 3B within the drawing surface by a predetermined amount ΔY in the main scanning direction (vertical direction) indicated by an

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arrow A with respect to the optical axis L. This makes it possible to make the center of an intensity distribution 14c of the light beam emitted from the semiconductor laser 2 coincide with substantially the center of the stop plate 5. As a consequence, an intensity distribution 15c of a light beam immediately before it is incident on the optical deflector 10 can be restored to the state shown in Fig. 3A. At this time, therefore, the illuminance distribution on the scanned surface becomes almost symmetrical about the axis. Note that the expression "almost symmetrical" indicates that the illuminance distribution on the scanned surface falls within $\pm 5\%$ with respect to the axis in the effective scanning range.

As described above, in this embodiment, the laser unit 1 is configured to be shifted by the shift adjusting means 23 in the main scanning direction with respect to the optical axis L of the incident optical system 21 so as to make the illuminance distribution, obtained when the scanned surface 12 is scanned with scanning lines, become almost symmetrical about the scanning central axis, thereby reducing the asymmetry of the illuminance distribution, obtained when the scanned surface is scanned with scanning lines, due to variations in components, assembly error, and the like. This makes it possible to obtain a high-quality image. In addition, in this embodiment, since the laser unit 1

formed by integrating the light source 2 and collimator lens 3 can be shifted in the main scanning direction, the illuminance distribution on the scanned surface can be easily adjusted. As long as the shift adjusting means 23 is integral with the laser unit 1 and allows initial adjustment, effects similar to those described above can be obtained.

In this embodiment, the laser unit 1 is configured to be shifted in the main scanning direction with respect to the optical axis L of the incident optical system 21. However, the present invention is not limited to this, and the laser unit 1 may be configured to be shifted in the sub-scanning direction. If this unit is configured to be shifted in the sub-scanning direction, the use efficiency of light improves with respect to a tilt in this direction, thus improving the reliability of the laser.

In the present invention, since the laser unit 1 formed by integrating the light source 2 and collimator lens 3 is shifted in a predetermined direction, and the optical axis of the semiconductor laser 2 coincides with that of the collimator lens 3, the parallel light beam emerging from the collimator lens 3 emerges parallel with the optical axis of the collimator lens. No focus error therefore occurs. Furthermore, since the laser unit 1 is formed by integrating the light source 2 and collimator lens 3, when the light source 2

fails, the laser unit 1 may be replaced with another. This makes it possible to reduce the cost in terms of market serviceability.

[Second Embodiment]

5 Fig. 4 is a sectional view (main scanning sectional view) of the main part of the second embodiment of the present invention in the main scanning direction. Fig. 5 is a sectional view (sub-scanning sectional view) of the main part in
10 Fig. 4 in the sub-scanning direction. The same reference numerals as in Figs. 1 and 2 denote the same parts in Figs. 4 and 5.

 This embodiment differs from the first embodiment describe above in that a light beam emerging from an
15 incident optical system 21 is obliquely incident on a deflecting surface 10a of an optical deflector 10 within a main scanning cross-section, and the incident optical system 21 is placed in a reflecting/deflecting (deflection scanning) plane based on the optical
20 deflector 10. Other arrangements and optical functions are substantially the same as those in the first embodiment, and hence similar effects are obtained.

 Since the optical axis of the incident optical system 21 in this embodiment is located in the same
25 drawing surface (main scanning cross-section) like the optical axis of a scanning lens system 24, the light beam emerging from a laser unit 1 is made to strike the

optical deflector 10 at an angle ϕ within the drawing surface so as not to interfere with the scanning lens system 24. In this arrangement, even if the chip of a semiconductor laser 2 is not tilted, since the position of a light beam cut by the deflecting surface 10a of the optical deflector 10 becomes an asymmetrical position with respect to an intensity distribution, the illuminance distribution of a spot imaged on a scanned surface 12 becomes asymmetrical.

In this embodiment, the laser unit 1 is placed to be shifted in advance in the main scanning direction (vertical direction) with respect to the optical axis of the incident optical system 21 by a predetermined amount corresponding to the angle ϕ to cancel out the asymmetry of the above illuminance distribution. In addition, even if the chip of the semiconductor laser 2 is tilted, the intensity distribution of a light beam immediately before it is incident on the optical deflector 10 can be adjusted to become almost symmetrical by adjusting the shift amount of the laser unit 1 in the main scanning direction in addition to the above means.

In this embodiment, the incident optical system 21 is formed by using a return mirror 7. However, the present invention is not limited to this, and can also be applied to an incident optical system without the return mirror as in the second embodiment.

[Third Embodiment]

The third embodiment of the present invention will be described next.

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5 This embodiment differs from the first embodiment described above in that a laser unit is shifted by a shift adjusting means in the main scanning direction (vertical direction) with respect to the optical axis of an incident optical system such that the ratio of the intensities of two light beams obtained by
10 splitting a light beam passing through a stop plate in two at the stop center in the main scanning direction becomes 10% or less. Other arrangements and optical functions are substantially the same as those in the first embodiment, and hence similar effects are
15 obtained.

To reduce the asymmetry of an illuminance distribution on a scanned surface due to variations in components, assembly errors, and the like, the ratio of the light intensities of light beams passing through
20 the stop plate in the main scanning direction must be set to 10% or less. In this embodiment, therefore, in consideration of parameters, e.g., a stop diameter w , a focal length f of a collimator lens, and an exit angle θ of a light beam from the semiconductor laser, the
25 laser unit is shifted by the shift adjusting means in the main scanning direction with respect to the optical axis of the incident optical system to reduce the

5 [Fourth Embodiment]

This embodiment differs from the first embodiment described above in that a semiconductor laser and collimator lens are integrated into a chip such that the tilt angle of the chip in the main scanning direction of the semiconductor laser is set to $\pm 2.5^\circ$ or less with respect to the optical axis of the collimator lens. Other arrangements and optical functions are substantially the same as those in the first embodiment, and hence similar effects are obtained.

The reason why the tilt angle of the chip in the main scanning direction of the semiconductor laser is set to $\pm 2.5^\circ$ or less with respect to the optical axis of the collimator lens will be described below.

Letting f be the focal length of the collimator lens and θ be the tilt angle of the chip in the main scanning direction, a shift amount L of the laser unit which is required to obtain a symmetrical intensity distribution is given by $L = f \cdot \tan \theta$. If $f = 35.2$ (mm), $\theta = 2.5^\circ$, and the stop diameter is 4.2 (mm), then $L = 1.53$ (mm). To make a light beam emerge from the laser

unit with a beam size large enough to stay within the stop diameter even if the laser unit is shifted by 1.54 (mm), at least a beam diameter of $4.2 \text{ (mm)} + 3.06 \text{ (mm)} = 7.26 \text{ (mm)}$ is required. In consideration of the effective diameter of the collimator lens, the receiving surface of a lens holding portion, and the like, the lens needs to have an outer size of 11 (mm). In this embodiment, therefore, the tilt angle of the semiconductor laser chip is set to $\pm 2.5^\circ$ or less with respect to the optical axis of the collimator lens, considering that as the chip tilts, the aperture of the lens increases to result in an increase in cost, and spherical aberration can be readily corrected, and that the tilt of the optical axis of the laser unit due to a shift must be suppressed.

According to this embodiment, this makes it possible to reduce the asymmetry of an illuminance distribution, obtained when the scanned surface is scanned with scanning lines, due to variations in components, assembly errors, and the like.

Note that the laser unit may be shifted in the main scanning direction or/and the sub-scanning direction with respect to the optical axis of the incident optical system as in the first embodiment.

Fig. 6 is a sectional view of the main part of an image forming apparatus according to an embodiment of the present invention. Referring to Fig. 6, an image

forming apparatus 104 receives code data Dc from an external device 117 such as a personal computer. This code data Dc is converted into image data (dot data) Di by a printer controller 111 in the apparatus. This
5 image data Di is input to an optical scanning unit 100 having an arrangement like the one described in each of the first to fourth embodiments. A light beam 103 modulated in accordance with the image data Di emerges from the optical scanning unit 100, and the
10 photosensitive surface of a photosensitive drum 101 is scanned in the main scanning direction with the light beam 103.

The photosensitive drum 101 serving as an electrostatic latent image carrier (photosensitive
15 member) is rotated clockwise by a motor 115. Upon this rotation, the photosensitive surface of the photosensitive drum 101 moves with respect to the light beam 103 in the sub-scanning direction perpendicular to the main scanning direction. A charging roller 102 for
20 uniformly charging the surface of the photosensitive drum 101 is placed above the photosensitive drum 101 such that the surface of the charging roller 102 is in contact with the photosensitive drum 101. The surface of the photosensitive drum 101 charged by the charging
25 roller 102 is irradiated with the light beam 103 scanned by the optical scanning unit 100.

As described above, the light beam 103 is

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is pressed against the fixing roller 113. The fixing unit fixes the unfixed toner image on the paper sheet 112 conveyed from the transfer unit by heating the paper sheet 112 while pressing it between the fixing roller 113 and the pressing portion of the press roller 114. In addition, a paper discharge roller 116 is placed behind the fixing roller 113 to discharge the image-fixed paper sheet 112 outside the image forming apparatus.

Although not shown in Fig. 6, the printer controller 111 controls the respective components in the image forming apparatus, including the motor 115, and the polygon motor in the optical scanning unit (to be described later) as well as data conversion described above.

In the first to fourth embodiments, the semiconductor laser 2 is exemplified as a single-beam laser. However, the present invention can be applied to a multi-beam laser. More specifically, a monolithic multi-beam semiconductor laser can be used. The number of lasers is not limited to two, and may be three or more.

According to the present invention, as described above, there is provided an optical scanning apparatus, in which the laser unit is configured to be shifted by the shift adjusting means in a predetermined direction with respect to the optical axis of the incident

optical system or/and the tilt angle of the
semiconductor laser chip is set to fall within an
allowable range so as to make an illuminance
distribution, obtained when a scanned surface is
5 scanned with scanning lines, almost symmetrical about
the scanning center axis so that the asymmetry of an
illuminance distribution, obtained when the scanned
surface is scanned with scanning lines, due to
variations in components, assembly errors, and the like
10 can be reduced, thereby forming a high-quality image.

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